

TJK/190/L.W.

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of Byoung-Youp KIM et al.) METHOD OF FORMING A MOCVD-TIN) THIN FILM
Korean Patent Appln. No. 2000-46691) ININ FILM)
Korean Filing Date: August 11, 2000))
PRELIMINARY AMENDMENT	
Assistant Commissioner for Patents Washington, D.C. 20231	
Dear Sir:	
Please amend the subject application as follows:	
In the Specification	
CROSS REFERENCE TO RELATED APPLICATION	
This application claims the priority of Korean patent application Serial No. 2000-46691	
filed on August 11, 2000.	
Pate: By: WILDMAN, HARROLD, ALLEN & DIXON WILDMAN, HARROLD, ALLEN & DIXON Timothy I. Keefer, Res. No. 35567 Timothy I.	